Application No.: 10/702,049 Docket No. FIS920060073US1 (RAJ-014)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of: Confirmation Number: 7419

FUKIAGE et al.

Application No.: 10/702,049 Group Art Unit: 1792

Filed: November 6, 2003 Examiner: Tadayyon Eslami, Tabassom

Title: METHOD OF IMPROVING POST-DEVELOP PHOTORESIST PROFILE ON A DEPOSITED DIELECTRIC FILM

AMENDMENT AFTER NON-FINAL REJECTION

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

In response to the Non Final Office Action dated November 01, 2007, the due date for response to which has been extended to April 01, 2008 by the attached Petition for a Two Month Extension of Time and Fee, please amend the above-identified application as follows: